

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Art Unit

: 1752

Examiner

: Barbara Lee Gilliam

Serial No.

: 09/890,926

Filed

: August 7, 2001 : Shinji Tanaka

Inventors

: Katsuhiro Uehara

Title

: PHOTOSENSITIVE RESIN

: PRINT PLATE MATERIAL

: AND PRODUCTION METHOD

: FOR PHOTOSENSITIVE : RESIN PRINT PLATE

Dated: June 11, 2003

Docket No.: 1265-01

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## **AMENDMENT**

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

In response to the Official Action dated December 13, 2002, Applicants amend as follows:

## In the Specification

Kindly amend the specification as follows:

## Page 2, third paragraph bridging page 3, kindly replace as follows:

Concretely, proposed are method (1) which is a method of forming an image on a photosensitive resin layer or on a thin film layer provided on a photosensitive resin layer, with toner or liquid ink, not requiring an original picture film (Japanese Patent Publication No. 20029/1983, Japanese Patent Laid-Open Nos. 110164/1991, 10709/1998, 10710/1998); method (2) which is a method of directly obtaining a printing plate by exposing a porous material or a photosensitive layer to laser rays followed by dissolving or subliming the exposed part (Japanese Patent Laid-Open Nos. 56601/1977, 127005/1978, Japanese Patent Publication No. 40033/1981,